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(54) Liquid crystal display device

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Description**1. FIELD OF THE INVENTION:**

5 [0001] The present invention relates to a liquid crystal display device for use as a display section of a notebook personal computer, a portable terminal apparatus, and the like.

2. DESCRIPTION OF THE RELATED ART:

10 [0002] Figure 9 is a circuit diagram illustrating a configuration of a conventional liquid crystal display device 10.

[0003] The liquid crystal display device 10 includes a plurality of switching elements (TFTs 2 in this example) which are arranged in a matrix pattern on an active matrix substrate (TFT substrate). The liquid crystal display device 10 also includes gate signal lines 3 for supplying gate signals for driving the TFTs 2 and source signal lines 4 for supplying display signals (source signals) to the TFTs 2. The gate signal lines 3 and the source signal lines 4 are arranged so as to cross each other. The gate electrode of each TFT 2 is electrically connected to the gate signal line 3, the source electrode of each TFT 2 is electrically connected to the source signal line 4, and the drain electrode of each TFT 2 is connected to a pixel electrode 1 and to one electrode of an auxiliary capacitor (Cs) 5. The other electrode of the auxiliary capacitor (Cs) 5 is connected to a common line 6. The TFT substrate opposes a counter substrate (color filter (CF) substrate) with a liquid crystal layer being interposed therebetween.

20 [0004] The liquid crystal display device 10 is driven, for example, by scanning the gate signal lines 3 upwardly or downwardly to turn ON the TFTs 2 along each gate signal line 3. A source signal is applied to each pixel (across the liquid crystal layer in that pixel) so as to charge the liquid crystal layer and the auxiliary capacitor 5 of that pixel to the potential of the source signal, whereby the potential of the liquid crystal layer in each pixel is kept constant after the TFT 2 is turned OFF until the pixel is scanned in the next sequence. Thus, an image is displayed on the liquid crystal display device 10.

[0005] When the liquid crystal material of the liquid crystal display device 10 is contaminated with an ionic impurity, some current is conducted through the liquid crystal layer before the next sequence so as to reduce the potential which has been applied across the liquid crystal layer. In such a case, a normal display cannot be maintained.

30 [0006] Such an ionic impurity may be any organic and inorganic impurity, e.g., Na^+ , Ca^{2+} , Cu^{2+} , Cl^- , OH^- , COOH^- , or the like. Such an ionic impurity may easily be introduced into the liquid crystal material during the production process of the liquid crystal display device.

35 [0007] In recent years, liquid crystal display devices have been used in portable terminal apparatuses. Therefore, attempts have been made in the art to reduce the power consumption of the liquid crystal display devices so that the portable terminal apparatuses can be used outdoor for a long period of time. Accordingly, it has been necessary to develop a liquid crystal material which can be driven with a low voltage. However, the capability of being driven with a low voltage means that the liquid crystal material has a large dielectric anisotropy, which in turn means that the liquid crystal material itself has a potential. Such a liquid crystal material itself is likely to attract an ionic substance, thereby increasing the probability that the liquid crystal material may be contaminated during the production process of the liquid crystal display device.

40 [0008] It is well known in the art that increasing the auxiliary capacitance Cs is effective to address these problems. However, increasing the auxiliary capacitance Cs has a problem of reducing the aperture area of each pixel. Then, in order to achieve a display brightness of a liquid crystal display device which is equivalent to that of other conventional liquid crystal display devices, it is necessary to increase the illuminance of the back light, which is the light source of the liquid crystal display device. However, the power consumption of a back light typically accounts for about 2/3 of the total power consumption of the liquid crystal display device. Therefore, the power consumption of the liquid crystal display device as a whole cannot be reduced in this way.

45 [0009] These problems have been addressed in the art by, for example, Japanese Laid-Open Publication Nos. 4-125617, 4-295824, 6-289408 and 8-201830, which disclose methods in which the surrounding region of the display pixel area is provided with an electrode pattern. An electric signal having a DC component is externally applied to the electrode pattern to adsorb the ionic impurity which has been introduced into the liquid crystal layer onto the electrode pattern, so as to maintain the purity of the liquid crystal layer in the display pixel area.

50 [0010] However, such conventional methods in which an electrode pattern is provided in the surrounding region of the display pixel area have the following problems.

55 [0011] In Japanese Laid-Open Publication No. 4-125617, an ion adsorption electrode pattern is provided on an active matrix substrate having TFTs provided thereon, while the display electrode on a CF substrate is not provided in a position opposing the electrode pattern.

[0012] However, the interval between a region of the display pixel area in which the ion adsorption electrode pattern is provided and a region in which a sealing material is provided is as small as about 1 mm to 3 mm. In order to ensure

that the display electrode on the CF substrate does not oppose the ion adsorption electrode pattern, this may be too small for methods which are typically employed in the prior art, i.e., methods in which display electrodes are patterned while directly masking the display electrode portions with a metal mask during the display electrode formation. Thus, it is necessary to pattern the display electrodes on the CF substrate with a photolithography technique, thereby increasing the number of production steps.

[0013] Moreover, when such an electrode pattern is provided on a typical liquid crystal display device, an interlayer insulating film is employed to electrically isolate the electrode pattern from the source or gate signal lines which cross the electrode pattern. However, an inorganic film of silicon nitride (SiN), or the like, which is typically employed for the interlayer insulating film is deposited by a CVD (chemical vapor deposition) method, and has a thickness of several hundreds of nanometers and a dielectric constant as high as 8. Therefore, depending upon the potential to be applied to the electrode pattern, the obtained display may be substantially affected by the capacitance at the intersection between the electrode pattern and the signal lines.

[0014] In addition, according to the drawings of Japanese Laid-Open Publication No. 4-125617, a protective film is provided on the electrode pattern. When a TFT production process is considered, the protective film needs to be deposited separately, thereby further increasing the number of production steps.

[0015] Japanese Laid-Open Publication No. 4-295824 discloses an arrangement in which an ion adsorption electrode pattern is provided between a display region and a sealing material. This conventional technique is directed primarily to duty drive type liquid crystal display devices. Therefore, the electrode pattern can be provided only in a direction parallel to segment lines and in a direction parallel to common lines. Signals are input to the segment lines and the common lines individually. However, in a liquid crystal display device with TFTs, in order to input signals other than the counter potential to the CF substrate, which corresponds to the substrate on which the common lines are provided, it is necessary to pattern the display electrodes on the CF substrate by a photolithography technique as in Japanese Laid-Open Publication No. 4-125617. Japanese Laid-Open Publication No. 8-201830 discloses a similar arrangement for liquid crystal display devices with TFTs. This arrangement also has a problem of increasing the number of production steps.

[0016] In Japanese Laid-Open Publication No. 6-289408, an ion adsorption electrode pattern can be formed from a conductive film which is also used to form the TFTs. Therefore, the problem of increasing the number of production steps, as needed in the above three patent publications, can be avoided. In the liquid crystal display device of Japanese Laid-Open Publication No. 6-289408, one or both of an alignment film or an overcoat film is removed above the electrode pattern so that an alternating voltage is applied to the electrode pattern and a DC potential is applied across the liquid crystal layer. Therefore, the region in which the electrode pattern is formed is different from the display pixel area. Thus, an asymmetric potential (=DC component) corresponding to the dielectric constant of the removed alignment film or overcoat film is generated and applied across the liquid crystal layer.

[0017] However, this arrangement presumes that an overcoat film is provided over the display electrodes in the display pixel area. Typically-employed liquid crystal display devices do not have any film other than the alignment film provided on the display electrodes. Therefore, this conventional technique differs from a liquid crystal display device of the present invention in terms of the basic structure.

[0018] Moreover, Japanese Laid-Open Publication No. 6-289408 states that the above-described effects can be obtained with a DC potential of 5 mV to 100 mV. However, in high definition type (XGA or SXGA type) liquid crystal display devices of which the diagonal screen size is about 10 inches or more have a DC potential difference in the display screen plane occurring due to a signal delay through signal lines and/or display electrodes on the CF substrate. A DC potential difference as large as 100 mV has been observed in such liquid crystal display devices. Therefore, it is believed that the conventional technique cannot improve the visible defects which occur due to ionic impurities as described above.

45 SUMMARY OF THE INVENTION

[0019] A liquid crystal display device according to the invention is defined in claim 1. Preferred embodiments of the liquid crystal display device are defined in the dependent claims.

[0020] The functions of the present invention will now be described.

[0021] As described above, the present invention provides a liquid crystal display device in which pixel electrodes are provided over gate signal lines and source signal lines via an interposing interlayer insulating film, wherein the interlayer insulating film extends to a surrounding region of a display pixel area (As used herein, the term "surrounding region of a display pixel area" refers to a region which surrounds the display pixel area and is outside the display pixel area) on which an electrode pattern for adsorbing an ionic impurity is provided. The electrode pattern can be formed simultaneously with the pixel electrode from the same material, thereby avoiding an increase in the number of production steps. Moreover, since an alignment film is provided on the electrode pattern, it is not necessary to separately provide a protective film, thereby eliminating the step of forming a protective film as in the prior art. Furthermore, since

the counter electrode on the counter substrate (CF substrate) can be provided on the electrode pattern, it is not necessary to pattern the counter electrode on the CF substrate by a photolithography technique, or the like.

[0022] The pixel electrodes may be provided to partially overlap at least one of the gate signal lines and the source signal lines. The liquid crystal display device of the present invention may be a reflective liquid crystal display device in which the pixel electrodes and the electrode pattern are made of a metal material having a reflective property.

[0023] The interlayer insulating film may be made of an organic material. In such a case, it is possible to reduce the capacitance at each of intersections between the electrode pattern and the signal lines. As described in Japanese Laid-Open Publication No. 9-96837, an acrylic resin, for example, has a dielectric constant of 3.7 and can be deposited to a thickness of 1.5 μm to 5 μm using a spin coating method. Therefore, the capacitance at each of the intersections can be 1/6 to 1/22 of that which would result when using a conventional insulating film made of silicon nitride, thereby reducing the influence on the display to a level such that the influence cannot be observed by the viewer.

[0024] An ionic impurity can be adsorbed onto the surface of the ionic impurity adsorbing electrode pattern by inputting a DC potential having the polarity opposite to that of the ionic impurity to the electrode pattern, thereby preventing the display quality from lowering due to the ionic impurity, while improving the reliability, as will be described below in Embodiments 1-3.

[0025] The electric signal is input to the ionic impurity adsorbing electrode pattern only to provide a potential difference across the liquid crystal layer and does not substantially flow as an electric current. Therefore, the electric signal can be supplied to the electrode pattern by using: a DC power supply for driving ICs, or the like, of driver circuits; a DC power supply for supplying a \pm potential for gate signals; a power supply for supplying rectangular wave signals such as source signals and common signals; and the like, which are used in the existing liquid crystal display devices.

[0026] By covering the ionic impurity adsorbing electrode pattern with an alignment film, an electrically attracted ionic impurity can be adsorbed onto the alignment film itself. Moreover, the alignment film can also function as an insulating film for preventing leakage between the electrode pattern and the counter electrodes on the counter substrate (CF substrate).

[0027] The ionic impurity adsorbing electrode pattern may be divided into a plurality of segments, and an electric signal may be individually input to each of the segments, as will be described below in Embodiment 3. Also in this way, it is possible to prevent visible defects due to an ionic impurity, while obtaining a good display.

[0028] Usually, contrast reductions are significant only along particular side/sides of the display pixel area. Therefore, the ionic impurity adsorbing electrode pattern is provided only along these sides, as in Embodiment 2 to be described below.

[0029] The liquid crystal display device of the present invention may be a reflective liquid crystal display device in which the pixel electrodes and the ion adsorption electrode pattern are made of a reflective metal material.

[0030] Thus, the invention described herein makes possible the advantages of providing a liquid crystal display device which is capable of avoiding visible defects occurring due to an ionic impurity which has been introduced into the liquid crystal layer, whose display is not influenced by input signals to the electrode pattern, which can be produced without increasing the number of production steps, and in which it is not necessary to separately provide a source of signal input for the electrode pattern.

[0031] These and other advantages of the present invention will become apparent to those skilled in the art upon reading and understanding the following detailed description with reference to the accompanying figures.

BRIEF DESCRIPTION OF THE DRAWINGS

[0032]

Figure 1 is a plan view illustrating a configuration of a liquid crystal display device according to Embodiment 1 not falling within the scope of the present invention;

Figure 2A is a cross-sectional view illustrating the configuration of the liquid crystal display device according to Embodiment 1;

Figure 2B is a cross-sectional view illustrating a configuration of a liquid crystal display device according to a variation of Embodiment 1;

Figure 3 is a plan view illustrating a distribution of contrast reductions for the liquid crystal display device according to Embodiment 1;

Figure 4 is a plan view illustrating a distribution of contrast reductions for another liquid crystal display device according to Embodiment 1 in which the rubbing directions are changed from those of the liquid crystal display

device shown in Figure 3;

5 Figure 5 is a plan view illustrating a configuration of a liquid crystal display device according to Embodiment 2 falling within the scope of the present invention;

10 Figure 6 is a plan view illustrating a configuration of another liquid crystal display device according to Embodiment 2 of the present invention;

15 Figure 7 is a plan view illustrating a configuration of still another liquid crystal display device according to Embodiment 2 of the present invention;

Figure 8 is a plan view illustrating a configuration of a liquid crystal display device according to Embodiment 3 of the present invention; and

15 Figure 9 is a circuit diagram illustrating a configuration of a conventional liquid crystal display device.

DETAILED DESCRIPTION

(Embodiment 1)

20 [0033] Figure 1 is a plan view illustrating a liquid crystal display device 100 according to Embodiment 1 not falling within the scope of the present invention. Figure 2A is a cross-sectional view illustrating the same. Figure 2B is a cross-sectional view illustrating a liquid crystal display device 100' according to a variation of Embodiment 1.

25 [0034] The liquid crystal display device 100 includes a TFT substrate 101 having pixel electrodes 202 provided thereon, and a CF substrate 102 having counter electrodes 206 provided thereon. The TFT substrate 101 and the CF substrate 102 oppose each other with a liquid crystal layer 110 being interposed therebetween. Each pixel is defined as an area interposed between one of the pixel electrodes 202 and a corresponding part of the counter electrodes 206. A sealing material 103 is provided in the surrounding region of a display pixel area 113 including the pixels. An electrode pattern 105 for adsorbing an ionic impurity is provided between the display pixel area 113 and the sealing material 103. In this embodiment, the display pixel area 113 of the liquid crystal display device 100 has a rectangular shape.

30 [0035] The TFT substrate 101 is provided with gate signal lines 203 for supplying gate signals for driving TFTs 201 and source signal lines 204 for supplying display signals (source signals) to the TFTs 201. The gate signal lines 203 and the source signal lines 204 are arranged to cross (perpendicular in this example) with each other. Each of the TFTs 201 is provided as a switching element in the vicinity of an intersection between one of the gate signal lines 203 and one of the source signal lines 204. The pixel electrodes 202 are provided so as to partially overlap at least one of the gate signal lines 203 and the source signal lines 204 via an interlayer insulating film 104 made of an organic material therebetween. Each pixel electrode 202 is connected to the drain electrode of the TFT 201 via a contact hole (not shown) in the interlayer insulating film 104. The material of the interlayer insulating film 104 is not limited to organic materials. For example, material of the interlayer insulating film 104 may be SiN_x or SiO_2 . An alignment film 111 is provided on the interlayer insulating film 104. The gate signal lines 203 and the source signal lines 204 extend beyond a frame region 114 into a terminal region 115 in which input terminals 108 of the gate signal lines 203 and the source signal lines 204 are provided. Signal voltages for driving the TFTs 201 are input to the gate signal lines 203 through the input terminals 108 thereof. Signal voltages of display data are input to the source signal lines 204 through the input terminals 108 thereof. The electrode pattern 105 is provided along the peripheral region of the interlayer insulating film 104 so as to surround the periphery of the display pixel area 113 with an extension into the terminal region 115. An electric signal is input to the electrode pattern 105 through the extension. The electric signal to be input to the electrode pattern 105 may be supplied from at least one of the power supply for the source driving circuit and the power supply for the gate driving circuit. As a result, it is not necessary to separately provide a source of signal input for the electrode pattern 105.

40 [0036] The CF substrate 102 includes a counter electrode 206 which is provided on a CF layer 207 having a black matrix 208. The alignment film 112 is provided over the CF layer 207 and the black matrix 208.

45 [0037] The TFT substrate 101 as described above can be produced as follows.

50 [0038] First, the TFTs 201 are provided on a substrate. The interlayer insulating film 104 is formed over the TFTs 201 by spincoating a photosensitive acrylic resin to a thickness of 3 μm . Contact holes (not shown) are provided in the interlayer insulating film 104. Then, the pixel electrodes 202 are formed by patterning an ITO (indium tin oxide) material by a sputtering method, and the drain electrodes of the TFTs 201 are respectively connected to the pixel electrodes 202 via the contact holes in the interlayer insulating film 104. During this production step, the electrode pattern 105 is

simultaneously formed from the ITO material from which the pixel electrodes **202** are formed. Then, the alignment film **111** is formed over the electrode pattern **105** and the pixel electrodes **202** and subjected to an alignment treatment such as rubbing. Thus, the TFT substrate **101** is produced.

[0039] Referring to Figure 2B, an interlayer insulating film **104'** may not be present under or outside the sealing material **103** region as long as the interlayer insulating film **104'** underlies the electrode pattern **105**.

[0040] The following reliability tests were conducted for the liquid crystal display device **100**.

[0041] First, the liquid crystal display device **100** was subjected to a conduction reliability test in a thermostat at 60°C without applying a voltage to the electrode pattern **105**. As a result, the contrast started to decrease along the peripheral portion of the display pixel area **113** at hour **300**, as shown in Table 1 below.

[0042] The "decrease" or "reduction" of the contrast as used herein refers to a condition where a black display (in the presence of an applied voltage) does not reach a sufficient darkness. The "decrease" or "reduction" of the contrast is not dependent upon the length of the signal writing period ("T_{on} period"), but is dependent upon the length of the signal retaining period ("T_{off} period"). When the T_{off} period is long, the darkness of the black display is reduced thereby making the black display appear whiter. When the T_{off} period is short, a black display reaches a sufficient darkness.

[0043] No change in the display was observed when the off voltage (V_{g1}), being dependent upon the off characteristics of TFTs, was varied in one direction. This shows that a leak defect occurred through the liquid crystal layer **110** due to the introduction of an ionic impurity into the liquid crystal layer **110**.

[0044] After the liquid crystal display device **100**, whose contrast has once been reduced, is left standing in a thermostat at a temperature equal to or greater than the phase transition temperature T_{ni} of the liquid crystal material for a few hours without electric conduction therethrough, the ionic impurity diffuses across the liquid crystal layer **110** and the defect disappears. In this way, the conduction reliability test was repeatedly conducted for the same liquid crystal display device **100**, which exhibited substantially the same defect at substantially the same time.

[0045] Then, after the contrast was recovered by leaving the device in a thermostat at a temperature equal to or greater than the phase transition temperature T_{ni} of the liquid crystal material for a few hours without electric conduction therethrough, the reliability test was conducted in a thermostat at 60°C while applying a DC voltage of +3.3 V through the electrode pattern **105**. Similarly, the reliability test was conducted with a DC voltage of -3.3 V. The results are shown in Table 1 below.

Table 1

Applied voltage(V)	Duration of reliability test (hours)									
	100	200	300	400	500	600	700	800	900	1000
0	○	○	Δ	×	×	×	×	×	×	×
+3.3	○	○	○	○	○	○	○	○	○	○
-3.3	○	○	Δ	×	×	×	×	×	×	×

○.... No stain observed
 Δ.... Stain observed only at corners (defective)
 ×.... Stain observed along entire sides (defective)

[0046] As can be seen from Table 1, the defect started to appear at around hour 300 both when no voltage was applied through the electrode pattern **105** and when a voltage of -3.3 V was applied therethrough. On the contrary, the defect did not appear in over 1000 hours of electrical conduction when +3.3 V was applied through the electrode pattern **105**.

[0047] It can be seen from the above that the cause of the reduction in the contrast of the display observed in this test is negative ion.

[0048] Then, after a voltage of +3.3 V was applied through the electrode pattern **105** followed by an electrical conduction through the liquid crystal layer for 1000 hours, the conduction test was continued in the absence of an applied voltage through the electrode pattern **105**. As a result, a defect occurred after **400** hours of electrical conduction through the liquid crystal layer **110**. Moreover, a device which once had the defect after applying no voltage through the electrode pattern **105** and a device which once had the defect after applying a voltage of -3.3 V through the electrode pattern **105** were applied with a voltage of +3.3 V through the electrode pattern **105** after the defect had occurred. As a result, for both devices, the defect disappeared in 24 hours. Thereafter, no defect was observed in these devices over 1000 hours of electrical conduction through the liquid crystal layer **110**.

[0049] Furthermore, a device which had the defect after a voltage application of +3.3 V through the electrode pattern **105** followed by an electrical conduction through the liquid crystal layer for 1000 hours and then no voltage application

therethrough for 500 hours, was left standing in a thermostat at a temperature equal to or greater than the phase transition temperature T_{ni} of the liquid crystal material for a few hours without electric conduction therethrough, the conduction test was conducted in the absence of an applied voltage through the electrode pattern 105. As a result, a defect occurred at hour 300.

5 [0049] In view of the above, it can be assumed that an ionic impurity once adsorbed onto the electrode pattern 105 is moved to and adsorbed onto the alignment film 111 provided on the surface of the electrode pattern 105.

[0050] Another test was conducted without providing the alignment film 111 on the surface of the electrode pattern 105.

10 [0051] The liquid crystal display device had a defect after 400 hours of electrical conduction through the liquid crystal layer when no voltage was applied through the electrode pattern. It was previously confirmed that this is a defect due to the individual difference which can be recovered by leaving the device standing in a thermostat at a temperature equal to or greater than the phase transition temperature T_{ni} of the liquid crystal material for a few hours without electric conduction therethrough, after which substantially the same defect occurs at substantially the same time when the reliability test is repeated, as in the reliability tests described above.

15 [0052] After applying a voltage of +3.3 V through the electrode pattern of the liquid crystal display device for 1000 hours, the conduction test was continued with no voltage application through the electrode pattern. As a result, a defect occurred after 20 hours of electrical conduction through the liquid crystal layer.

20 [0053] It is believed that the defect occurred in such a short period of time because the ionic impurity dispersed across the liquid crystal layer was once attracted to and adsorbed onto the electrode pattern, but then lost the potential for adsorption and started to diffuse from the electrode pattern.

[0054] This also shows that the alignment film has an effect of adsorbing an ionic impurity onto the surface thereof.

[0055] In the liquid crystal display device of the present embodiment, the pixel electrodes on the interlayer insulating film may or may not partially overlap at least one of the gate signal lines and the source signal lines.

25 [0056] The liquid crystal display device of the present embodiment may be a reflective liquid crystal display device in which the pixel electrodes and the ionic impurity adsorbing electrode pattern on the interlayer insulating film are made of a reflective metal material.

(Embodiment 2)

30 [0057] In Embodiment 2, the arrangement of the ionic impurity adsorbing electrode pattern will be discussed.

[0058] In Embodiment 1 above, the electrode pattern 105 is arranged to completely surround the display pixel area 113. However, the reduction in the contrast of the display has a distribution as shown in Figure 3, and the electrode pattern 105 may partially be omitted in view of such a distribution.

35 [0059] The rubbing directions of the liquid crystal display device 100 of the present embodiment are as shown in Figure 3. For illustration purposes, in the following description, the upper left, lower left, lower right and upper right corners of the liquid crystal display device 100 will be referred to as "first corner 120", "second corner 130", "third corner 140" and "fourth corner 150", respectively. Referring to Figure 3, the rubbing direction on the CF substrate 102 is represented by an arrow 301 which extends generally from the second corner 130 to the fourth corner 150, and the rubbing direction on the TFT substrate 101 is represented by an arrow 302 which extends generally from the first corner 120 to the third corner 140. Herein, for the sake of simplicity, the rubbing direction of an alignment film on each substrate is represented by a single arrow which points to a corner of the display pixel area 113. It is understood, however, that the rubbing treatment is actually performed across the entire surface of the alignment film, not only along a single line thereon. It is shown in Figure 3 that the contrast reductions are significant along particular sides of the display pixel area 113, i.e., a side which is interposed between the head of the arrow 302 (corresponding to the third corner 140) and the head of the arrow 301 (corresponding to the fourth corner 150), another side which is interposed between the tail of the arrow 302 (corresponding to the first corner 120) and the head of the arrow 301 (corresponding to the fourth corner 150), and still another side which is interposed between the head of the arrow 302 (corresponding to the third corner 140) and the tail of the arrow 301 (corresponding to the second corner 130).

40 [0060] In order to verify the cause of the contrast reductions, the contrast of the display was observed for a liquid crystal display device 200 in which the rubbing directions are changed from those of the liquid crystal display device 100 as shown in Figure 4. The rubbing direction on the CF substrate of the liquid crystal display device 200 is represented by an arrow 303 which extends generally from the fourth corner 150 to the second corner 130, and the rubbing direction on the TFT substrate is represented by an arrow 304 which extends generally from the third corner 140 to the first corner 120. Thus, the rubbing directions on the CF substrate and the TFT substrate of the liquid crystal display device 200 (which are represented by the arrows 303 and 304, respectively) are opposite respectively to those on the CF substrate and the TFT substrate of the liquid crystal display device 100 (which are represented by the arrows 301 and 302, respectively). As shown in Figure 4, in the liquid crystal display device 200, the contrast reductions were significant along particular sides of the display pixel area 113, i.e., a side which is interposed between the head of the

arrow **304** (corresponding to the first corner **120**) and the head of the arrow **303** (corresponding to the second corner **130**), another side which is interposed between the tail of the arrow **304** (corresponding to the third corner **140**) and the head of the arrow **303** (corresponding to the second corner **130**), and still another side which is interposed between the head of the arrow **304** (corresponding to the first corner **120**) and the tail of the arrow **303** (corresponding to the fourth corner **150**).

[0061] In view of the above, another liquid crystal display device **300** was produced as shown in Figure 5, with the same rubbing directions on the CF substrate and the TFT substrate (represented by the arrows **301** and **302**, respectively) as those of the liquid crystal display device **100** shown in Figure 3. In the liquid crystal display device **300**, an electrode pattern **105A** was provided only along the three sides of the display pixel area along which the contrast reductions were significant. Specifically, the electrode pattern **105A** is provided along three sides of the display pixel area, i.e., a side which is interposed between the head of the arrow **302** (corresponding to the third corner **140**) and the head of the arrow **301** (corresponding to the fourth corner **150**), another side which is interposed between the tail of the arrow **302** (corresponding to the first corner **120**) and the head of the arrow **301** (corresponding to the fourth corner **150**), and still another side which is interposed between the head of the arrow **302** (corresponding to the third corner **140**) and the tail of the arrow **301** (corresponding to the second corner **130**). The liquid crystal display device **300** has an electrode pattern **105A** which is substantially the same as the electrode pattern **105** of the liquid crystal display device **100** except that the electrode pattern **105A** does not extend along the left side of the display pixel area.

[0062] A reliability test as that described in Embodiment 1 was conducted for the liquid crystal display device **300**. As a result, a defect occurred after 300 hours of electrical conduction through the liquid crystal layer when no voltage was applied through the electrode pattern **105A**. On the contrary, no defect occurred in over 1000 hours of electrical conduction through the liquid crystal layer when a voltage of +3.3 V was applied through the electrode pattern **105A**.

[0063] Figure 6 illustrates still another liquid crystal display device **400** having the same rubbing directions on the CF substrate and the TFT substrate (represented by the arrows **301** and **302**, respectively) as those of the liquid crystal display device **100** shown in Figure 3. In the liquid crystal display device **400**, an electrode pattern **105B** was provided only along one side of the display pixel area which is interposed between the head of the arrow **301** (corresponding to the fourth corner **150**) and the head of the arrow **302** (corresponding to the third corner **140**). A reliability test as that described in Embodiment 1 was conducted for the liquid crystal display device **400**. The electrode pattern **105B** of the liquid crystal display device **400** is substantially the same as those of the liquid crystal display devices **100** and **300** except that the electrode pattern **105B** extends only along the right side of the display pixel area **113** (i.e., between the third corner **140** and the fourth corner **150**). As a result, a defect occurred after 300 hours of electrical conduction through the liquid crystal layer when no voltage was applied through the electrode pattern **105B**. On the contrary, when a voltage of +3.3 V was applied through the electrode pattern **105B**, no defect occurred after 700 hours of electrical conduction through the liquid crystal layer. After 800 hours, however, a defect occurred along a side of the display pixel area extending between the first corner **120** and the fourth corner **150** and along another side of the display pixel area extending between the second corner **130** and the third corner **140**.

[0064] The electrode pattern of the present invention does not have to be provided along each of these three sides of the display pixel area. The electrode pattern of the present invention may be provided along at least one side of the display pixel area.

[0065] For example, with the generally rectangular display pixel area, the electrode pattern may be provided along two sides which are connected together by a corner of the generally rectangular display pixel area which is pointed to by an arrow representing the rubbing direction on one of the pair of substrates. Alternatively, the electrode pattern may be provided along a first pair of sides which are connected together by a corner of the generally rectangular display pixel area which is pointed to by an arrow representing the rubbing direction on one of the pair of substrates, and also along a second pair of sides which are connected together by another corner of the generally rectangular display pixel area which is pointed to by another arrow representing the rubbing direction on the other one of the pair of substrates. The first pair of sides and the second pair of sides share one side with each other. This will be discussed in greater detail below with reference to Figure 7, which illustrates a liquid crystal display device **400'** having an electrode pattern **105C**. In the illustrated example, the head of the arrow **301** representing the rubbing direction on the CF substrate points to the fourth corner **150**. Therefore, the electrode pattern may be provided along two sides which are connected together by the fourth corner **150** (i.e., the side extending between the first corner **120** and the fourth corner **150**, and the side extending between the third corner **140** and the fourth corner **150**). Alternatively, the electrode pattern may be provided along two pairs of sides, each pair of sides being connected together by a corner of the generally rectangular display pixel area which is pointed to by an arrow representing the rubbing direction on one of the pair of substrates. The two pairs of sides share one side with each other. Since the display pixel area is in a rectangular shape, the electrode pattern may be provided as the electrode pattern **105A** of the liquid crystal display device **300** shown in Figure 5.

[0066] In each liquid crystal display device of the present embodiment, the pixel electrodes on the interlayer insulating film may or may not partially overlap at least one of the gate signal lines and the source signal lines.

[0067] Each liquid crystal display device of the present embodiment may be a reflective liquid crystal device in which the pixel electrodes and the ionic impurity adsorbing electrode pattern on the interlayer insulating film are made of a reflective metal material.

5 (Embodiment 3)

[0068] Figure 8 illustrates a liquid crystal display device 500 according to Embodiment 3 of the present invention, with the same rubbing directions on the CF substrate and the TFT substrate (represented by the arrows 301 and 302, respectively) as those of the liquid crystal display device 100 shown in Figure 3. As shown in Figure 8, the liquid crystal display device 500 includes an electrode pattern which is divided into three segments 105E, 105F and 105G to each of which any electric potential is applied. The electrode pattern segments 105E, 105F and 105G are provided a side extending between the third corner 140 and the fourth corner 150, a side extending between the second corner 130 and the third corner 140, and a side extending between the fourth corner 150 and the first corner 120. A reliability test was conducted with a voltage application of +3.3 V through the electrode pattern segment 105E and +5.5 V through each of the electrode pattern segments 105F and 105G. As a result, the liquid crystal display device 500 did not have a defect in over 1000 hours of electrical conduction through the liquid crystal layer.

[0069] This shows that an electrode pattern can be divided into a plurality of segments to each of which any electric potential is applied individually as long as it is possible to apply through each electrode pattern segment a potential whose polarity is opposite to that of the ionic impurity to be adsorbed.

[0070] In the liquid crystal display device of the present embodiment, the pixel electrodes on the interlayer insulating film may or may not partially overlap at least one of the gate signal lines and the source signal lines.

[0071] The liquid crystal display device of the present embodiment may be a reflective liquid crystal device in which the pixel electrodes and the ionic impurity adsorbing electrode pattern segments on the interlayer insulating film are made of a reflective metal material.

[0072] In each of the above-described embodiments of the present invention, an acrylic resin is used as the interlayer insulating film. However, the interlayer insulating film may be made of any organic material such as acrylic resins or fluorine resins, TEOS (tetra ethyl ortho silicate), and the like. Preferred materials for the interlayer insulating film are those with which the interlayer insulating film can be deposited to a large thickness and which have a small dielectric constant.

[0073] As described above, the present invention provides a liquid crystal display device in which pixel electrodes are provided over gate signal lines and source signal lines via an interlayer insulating film interposed therebetween, wherein the interlayer insulating film extends to a surrounding region of a display pixel area on which an electrode pattern for adsorbing an ionic impurity is provided. The electrode pattern can be formed simultaneously with the pixel electrode from the same material, and it is not necessary to provide a protective film on the electrode pattern. Thus, it is possible to provide a liquid crystal display device having a good display quality without increasing the number of production steps.

[0074] An ionic impurity can be adsorbed onto the surface of the ionic impurity adsorbing electrode pattern by inputting a DC potential having the polarity opposite to that of the ionic impurity to the electrode pattern, thereby preventing the display quality from lowering due to the ionic impurity while improving the reliability over a long period of time.

[0075] Moreover, since the interlayer insulating film is made of an organic material, it is possible to reduce the capacitance at each intersection between the electrode pattern and a signal line, thereby preventing the capacitance from influencing the display quality.

[0076] An electric signal can be supplied to the electrode pattern by using: a DC power supply for driving ICs, or the like, of driver circuits; a DC power supply for supplying a \pm potential for gate signals; a power supply for supplying rectangular wave signals such as source signals and common signals; and the like, which are used in the existing liquid crystal display devices. Therefore, it is not necessary to provide a separate source of input signal.

[0077] By covering the ionic impurity adsorbing electrode pattern with an alignment film, an electrically attracted ionic impurity can be adsorbed onto the alignment film itself, thereby further improving the reliability.

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Claims

1. A liquid crystal display device (100), comprising:

55 a pair of substrates (101,102) opposing each other;
 a liquid crystal layer (110) interposed between the pair of substrates (101,102);
 a plurality of switching elements (201) arranged in a matrix pattern on one of the pair of substrates (101,102),
 said matrix pattern defining a display pixel area;

gate signal lines (203) arranged on corresponding lines of the matrix of switching elements (201) for supplying gate signals for driving the switching elements (201);
 5 source signal lines (204) crossing the gate signal lines (203) for supplying display signals to the switching elements (201);
 an interlayer insulating film (104) provided over the gate signal lines (203) and the source signal lines (204); and
 pixel electrodes (202) provided over the gate signal lines (203) and the source signal lines (204) via the interlayer insulating film (104), wherein:

10 the interlayer insulating film (104) extends to a surrounding region of the display pixel area;
 the display pixel area has a generally rectangular shape;
 the pair of substrates (101,102) are arranged so that a rubbing direction of one of the substrates which is represented by a first arrow crosses a rubbing direction of the other one of the substrates (101,102) which is represented by a second arrow, the first and second arrow each extending from its tail to its head, the first arrow pointing to a first corner of the display pixel area, and the second arrow pointing to a second corner of the display pixel area, the first corner and the second corner sharing one first side of the display pixel area with each other;
 15 an electrode pattern (105) for adsorbing ionic impurities is provided on the interlayer insulating film (104) in the surrounding region at least along said first side interposed between the head of the first arrow and the head of the second arrow, where significant contrast reductions occur due to ionic impurities; and
 20 a second side of said display pixel area which is opposite to said first side is devoid of said electrode pattern (105).

2. A liquid crystal display device according to claim 1 wherein the electrode pattern (105) extends at least along a further side of the display pixel area which is connected together to said first side by the corner that is pointed to by the first and/or second arrow.

3. A liquid crystal display device according to claim 1 or 2, wherein the pixel electrodes (202) are provided to partially overlap at least one of the gate signal lines (203) and the source signal lines (204).

30 4. A liquid crystal display device according to any one of claims 1 to 3, wherein the pixel electrodes (202) and the electrode pattern (105) are made of a metal material having a reflective property.

5. A liquid crystal display device according to any one of claims 1 to 4, wherein the electrode pattern (105) is provided inward with respect to a sealing material (103) with which the pair of substrates (101,102) are attached together.

35 6. A liquid crystal display device according to any one of claim 1 to 5, wherein the electrode pattern (105) is covered with an alignment film (111,112).

40 7. A liquid crystal display device according to any one of claims 1 to 6, wherein an electric signal having a DC potential is input to the electrode pattern (105).

8. A liquid crystal display device according to any one of claims 1 to 7, wherein an electric signal which is input to the electrode pattern (105) is supplied from at least one of a power supply for a source driving circuit and a power supply for a gate driving circuit.

45 9. A liquid crystal display device according to any one of claims 1 to 8, wherein:

the electrode pattern (105) is divided into a plurality of segments; and
 an electric signal is individually input to each of the segments.

50 10. A liquid crystal display device according to any one of claims 1 to 9, wherein the interlayer insulating film (104) is made of an organic material.

11. A liquid crystal display device according to any one of claims 1 to 10, wherein the electrode pattern (105) is formed simultaneously with the pixel electrodes (202).

Patentansprüche**1. Flüssigkristallanzeigevorrichtung (100) mit:**

- 5 - einem Paar Substrate (101, 102), die sich einander gegenüber stehen,
- einer Flüssigkristallschicht (110), welche zwischen dem Paar Substrate (101, 102) angeordnet ist,
- einer Mehrzahl Schaltelemente (201), welche in Matrixform auf einem der Substrate (101, 102) angeordnet ist, wobei die Matrixform einen Anzeigepixelbereich definiert,
- Gatesignalleitungen (203), welche auf korrespondierenden Leitungen der Matrix der Schaltelement (201) angeordnet sind zum Zuführen von Gatesignalen zum Antreiben oder Betreiben der Schaltelemente (201),
- Sourcesignalleitungen (204), welche die Gatesignalleitungen (203) kreuzen, zum Zuführen von Anzeigesignalen zu den Schaltelementen (201),
- einer Zwischenisolationsschicht (104), welche über den Gatesignalleitungen (203) und den Sourcesignalleitungen (204) vorgesehen ist, und
- 15 - Pixelelektroden (202), welche über den Gatesignalleitungen (203) und den Sourcesignalleitungen (204) mittels oder durch die Zwischenisolationsschicht (104) vorgesehen sind, wobei:
 - die Zwischenisolationsschicht (104) sich zu einem Umgebungsbereich des Anzeigepixelbereichs erstreckt,
 - der Anzeigepixelbereich eine im Allgemeinen rechteckige Form aufweist,
 - das Paar Substrate (101, 102) derart angeordnet ist, dass eine Polierrichtung eines der Substrate, welches durch einen ersten Pfeil repräsentiert wird, des anderen Substrats (101, 102) kreuzt, welche durch einen zweiten Pfeil repräsentiert wird, wobei die ersten und zweiten Pfeile sich jeweils von ihrem Ende zu ihrem Anfang erstrecken, wobei der erste Pfeil in eine erste Ecke des Anzeigepixelbereichs zeigt und wobei der zweite Pfeil in eine zweite Ecke des Anzeigepixelbereichs zeigt, wobei die erste Ecke und die zweite Ecke eine gemeinsame Seite oder Kante des Anzeigepixelbereichs aufweisen,
 - eine Elektrodenanordnung (105) oder ein Elektrodenmuster (105) zum Adsorbieren oder Aufnehmen ionischer Fremdstoffe oder Verunreinigungen auf der Zwischenisolationsschicht (104) im Umgebungsbe- reich zumindest entlang der ersten Seite zwischen der Spitze des ersten Pfeils und der Spitze des zweiten Pfeils angeordnet ist, wo signifikante Kontrastverminderungen aufgrund der ionischen Fremdstoffe oder Verunreinigungen auftreten.

2. Flüssigkristallanzeigeeinrichtung nach Anspruch 1,

bei welcher die Elektrodenanordnung (105) oder das Elektrodenmuster (105) sich zumindest entlang einer weiteren Seite des Anzeigepixelbereichs erstreckt, welche mit der ersten Seite durch diejenige Ecke verbunden ist, auf welche der erste und/oder der zweite Pfeil zeigt.

3. Flüssigkristallanzeigeeinrichtung nach einem der Ansprüche 1 oder 2,

bei welcher die Pixelelektroden (202) teilweise überlappend vorgesehen sind, der zumindest an einer der Gatesignalleitungen (203) und der Sourcesignalleitungen (204).

4. Flüssigkristallanzeigeeinrichtung nach einem der Ansprüche 1 bis 3,

bei welcher die Pixelelektroden (202) und die Elektrodenanordnung (105) oder das Elektrodenmuster (105) gebildet sind aus einem metallischen Material mit reflektiven Eigenschaften oder Reflexionseigenschaften.

45 5. Flüssigkristallanzeigeeinrichtung nach einem der Ansprüche 1 bis 4,

bei welcher die Elektrodenanordnung (105) oder das Elektrodenmuster (105) in Bezug auf ein Versiegelungsmaterial (103), mit welchem das Paar Substrate (101, 102) aneinandergefügt ist, einwärts gerichtet ausgebildet sind.

50 6. Flüssigkristallanzeigeeinrichtung nach einem der Ansprüche 1 bis 5,

bei welcher das Elektrodenmuster (105) oder die Elektrodenanordnung (105) mit einer Anordnungsschicht (111, 112) abgedeckt sind.

7. Flüssigkristallanzeigeeinrichtung nach einem der Ansprüche 1 bis 6,

bei welcher ein elektrisches Signal mit einem DC-Potenzial an die Elektrodenanordnung (105) oder an das Elektrodenmuster (105) angelegt wird.

55 8. Flüssigkristallanzeigeeinrichtung nach einem der Ansprüche 1 bis 7,

bei welcher das elektrische Signal, welches an das Elektrodenmuster (105) oder an die Elektrodenanordnung (105) angelegt wird, von zumindest einer Spannungsversorgung für einen Sourcebetriebsschaltkreis oder einer Spannungsversorgung für einen Gatebetriebskreis zugeführt wird.

5 9. Flüssigkristallanzeigeeinrichtung nach einem der Ansprüche 1 bis 8,

- bei welcher die Elektrodenanordnung (105) oder das Elektrodenmuster (105) in eine Mehrzahl Segmente unterteilt sind und
- bei welcher ein elektrisches Signal individuell an jedes der Segmente angelegt wird.

10 10. Flüssigkristallanzeigeeinrichtung nach einem der Ansprüche 1 bis 9,
bei welcher die Zwischenisolationsschicht (104) aus einem organischen Material gebildet ist.

15 11. Flüssigkristallanzeigeeinrichtung nach einem der Ansprüche 1 bis 10,
bei welcher die Elektrodenanordnung (105) oder das Elektrodenmuster (105) simultan mit den Pixelelektroden (202) ausgebildet ist.

Revendications

20 1. Dispositif d'affichage à cristal liquide (100) comprenant :

deux substrats (101, 102) en regard l'un de l'autre;

une couche de cristal liquide (110) intercalée entre les deux substrats (101, 102);

une pluralité d'éléments de commutation (201) aménagés en configuration matricielle sur l'un des deux substrats (101, 102), ladite configuration matricielle définissant une surface de pixels d'affichage;

des lignes de signal de grille (203) aménagées sur des lignes correspondantes de la matrice d'éléments de commutation (201) pour fournir des signaux de grille afin d'exciter les éléments de commutation (201);

des lignes de signal de source (204) croisant les lignes de signal de grille (203) pour fournir des signaux d'affichage aux éléments de commutation (201);

un film isolant intermédiaire (104) appliqué par-dessus les lignes de signal de grille (203) et les lignes de signal de source (204); et

des électrodes de pixels (202) appliquées par-dessus les lignes de signal de grille (203) et les lignes de signal de source (204) via le film isolant intermédiaire (104); dans lequel :

35 le film isolant intermédiaire (104) s'étend jusqu'à une région environnante de la surface de pixels d'affichage;

la surface de pixels d'affichage a une forme généralement rectangulaire;

40 les deux substrats (101, 102) sont aménagés de manière qu'une direction de polissage de l'un des substrats qui est représentée par une première flèche croise une direction de polissage de l'autre des substrats (100, 102) qui est représentée par une seconde flèche, la première et la seconde flèches s'étendant chacune de leur queue à leur tête, la première flèche pointant vers un premier coin de la surface de pixels d'affichage et la seconde flèche pointant vers un second coin de la surface de pixels d'affichage, le premier coin et le second coin partageant un premier côté de la surface de pixels d'affichage l'un avec l'autre;

45 une configuration d'électrodes (105) pour adsorber les impuretés ioniques est prévu sur le film isolant intermédiaire (104) dans la région environnante au moins le long dudit premier côté intercalé entre la tête de la première flèche et la tête de la seconde flèche, où des réductions de contraste importantes se produisent en raison des impuretés ioniques; et

50 un second côté de ladite surface de pixels d'affichage qui est opposé audit premier côté est dépourvu de ladite configuration d'électrodes (105).

55 2. Dispositif d'affichage à cristal liquide selon la revendication 1, dans lequel la configuration d'électrodes (105) s'étend au moins le long d'un autre côté de la surface de pixels d'affichage qui est connectée conjointement avec ledit premier côté par le coin sur lequel est pointée la première flèche et/ou la seconde flèche.

55 3. Dispositif d'affichage à cristal liquide selon la revendication 1 ou 2, dans lequel les électrodes de pixels (202) sont prévues de manière à chevaucher partiellement au moins l'une des lignes de signal de grille (203) et les lignes de signal de source (204).

4. Dispositif d'affichage à cristal liquide selon l'une quelconque des revendications 1 à 3, dans lequel les électrodes de pixels (202) et la configuration d'électrodes (105) sont constituées d'un matériau métallique ayant une propriété réfléchissante.

5. Dispositif d'affichage à cristal liquide selon l'une quelconque des revendications 1 à 4, dans lequel la configuration d'électrodes (105) est ménagée vers l'intérieur par rapport à un matériau d'étanchéité (103) avec lequel les deux substrats (101, 102) sont fixés ensemble.

10. 6. Dispositif d'affichage à cristal liquide selon l'une quelconque des revendications 1 à 5, dans lequel la configuration d'électrodes (105) est revêtue d'un film d'alignement (111, 112).

7. Dispositif d'affichage à cristal liquide selon l'une quelconque des revendications 1 à 6, dans lequel un signal électrique ayant un potentiel en courant continu est délivré à la configuration d'électrodes (105).

15. 8. Dispositif d'affichage à cristal liquide selon l'une quelconque des revendications 1 à 7, dans lequel un signal électrique qui est délivré à la configuration d'électrodes (105) est délivrée à partir d'au moins une alimentation en énergie pour un circuit d'excitation de source et une alimentation en énergie pour un circuit d'excitation de grille.

20. 9. Dispositif d'affichage à cristal liquide selon l'une quelconque des revendications 1 à 8, dans lequel la configuration d'électrodes (105) est divisée en une pluralité de segments et un signal électrique est individuellement délivré à chacun des segments.

25. 10. Dispositif d'affichage à cristal liquide selon l'une quelconque des revendications 1 à 9, dans lequel la couche isolante intermédiaire (104) est constituée d'un matériau organique.

11. Dispositif d'affichage à cristal liquide selon l'une quelconque des revendications 1 à 10, dans lequel la configuration d'électrodes (105) est formée simultanément avec les électrodes de pixels (202).

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FIG. 1

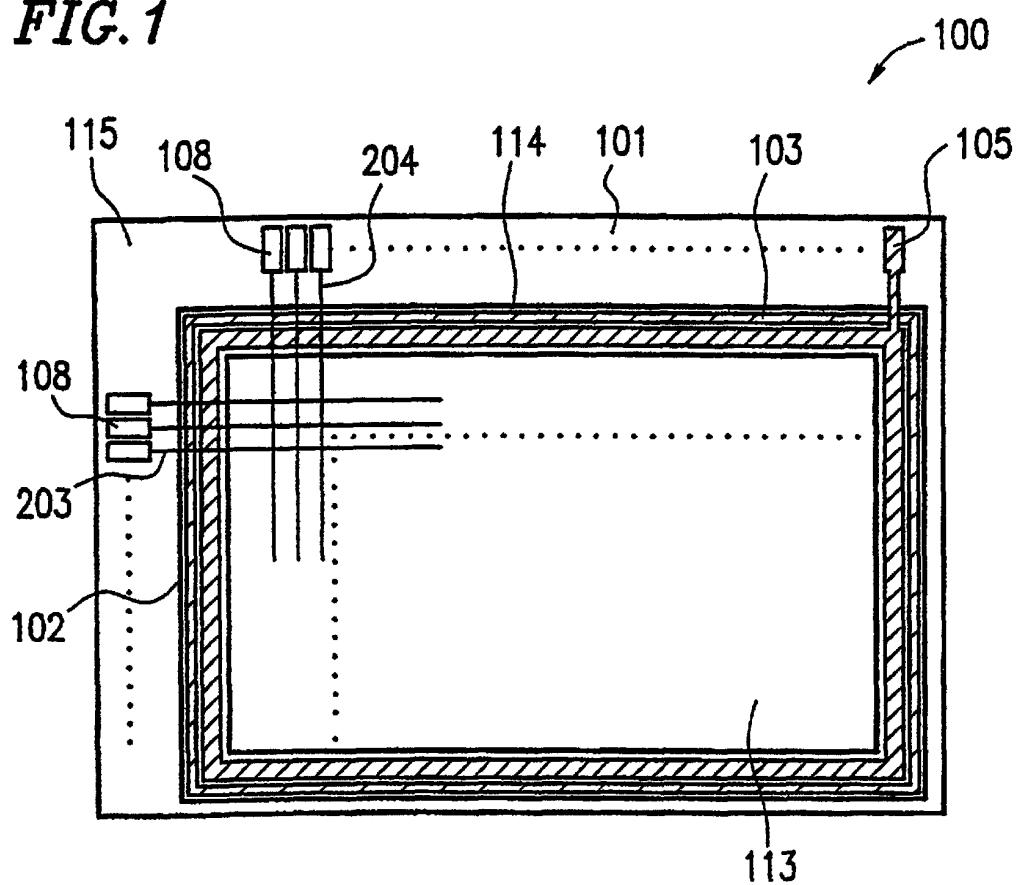


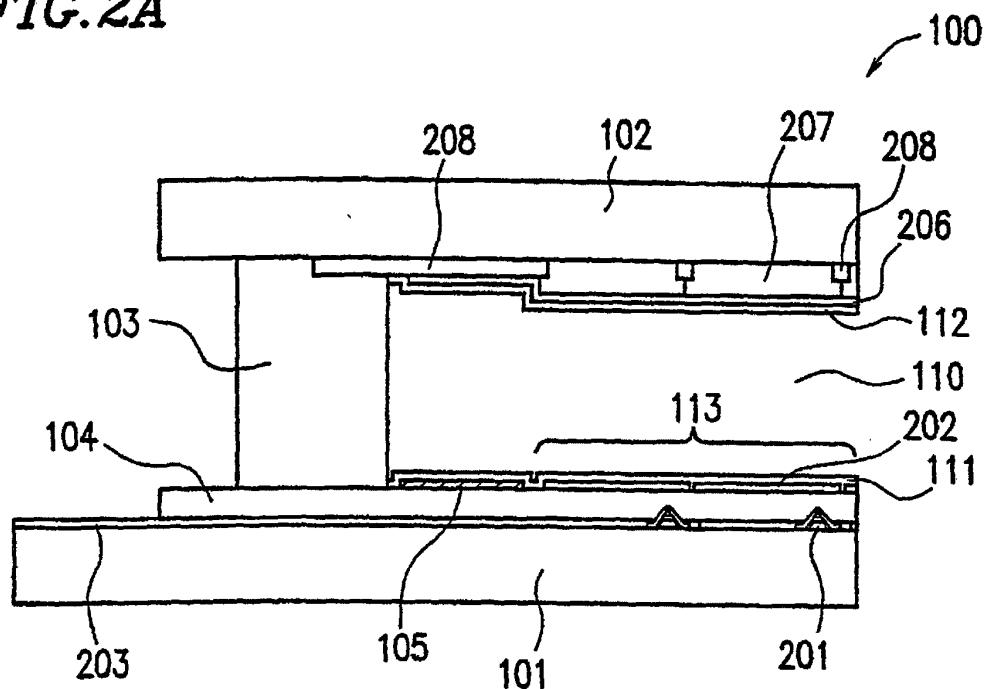
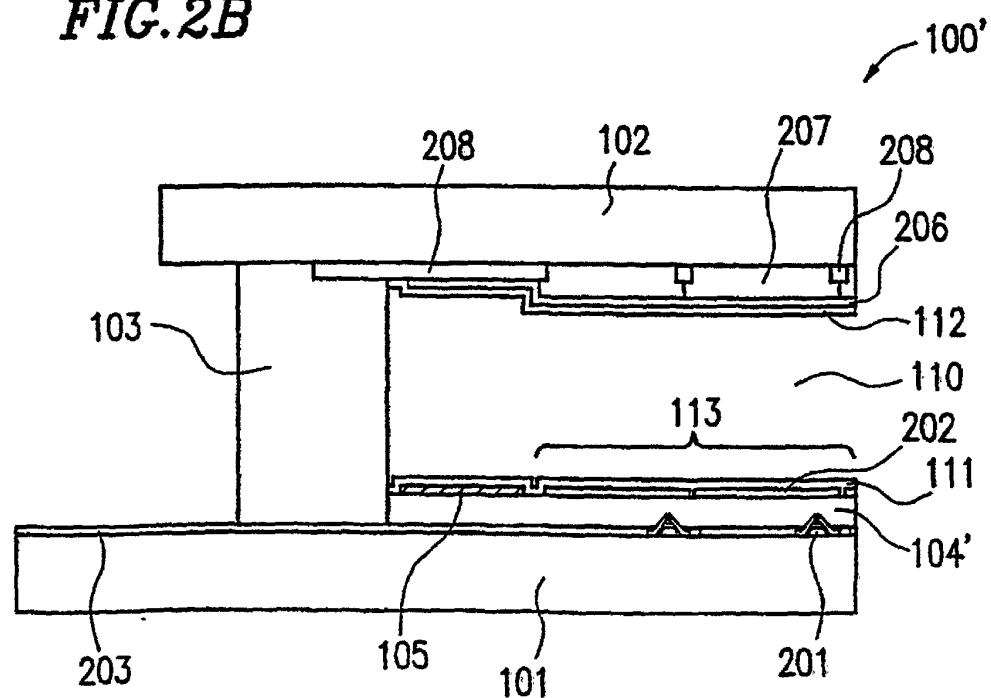
FIG. 2A**FIG. 2B**

FIG. 3

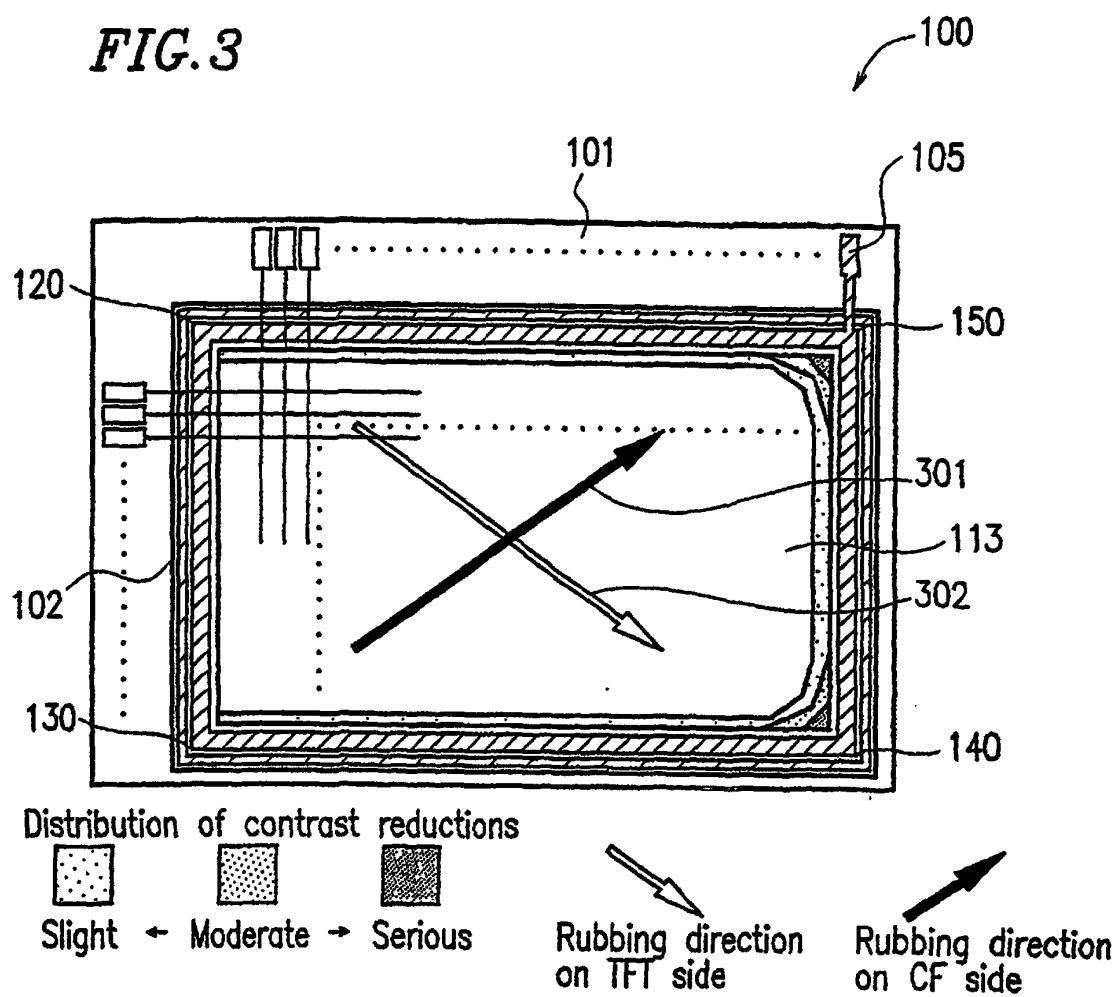


FIG. 4

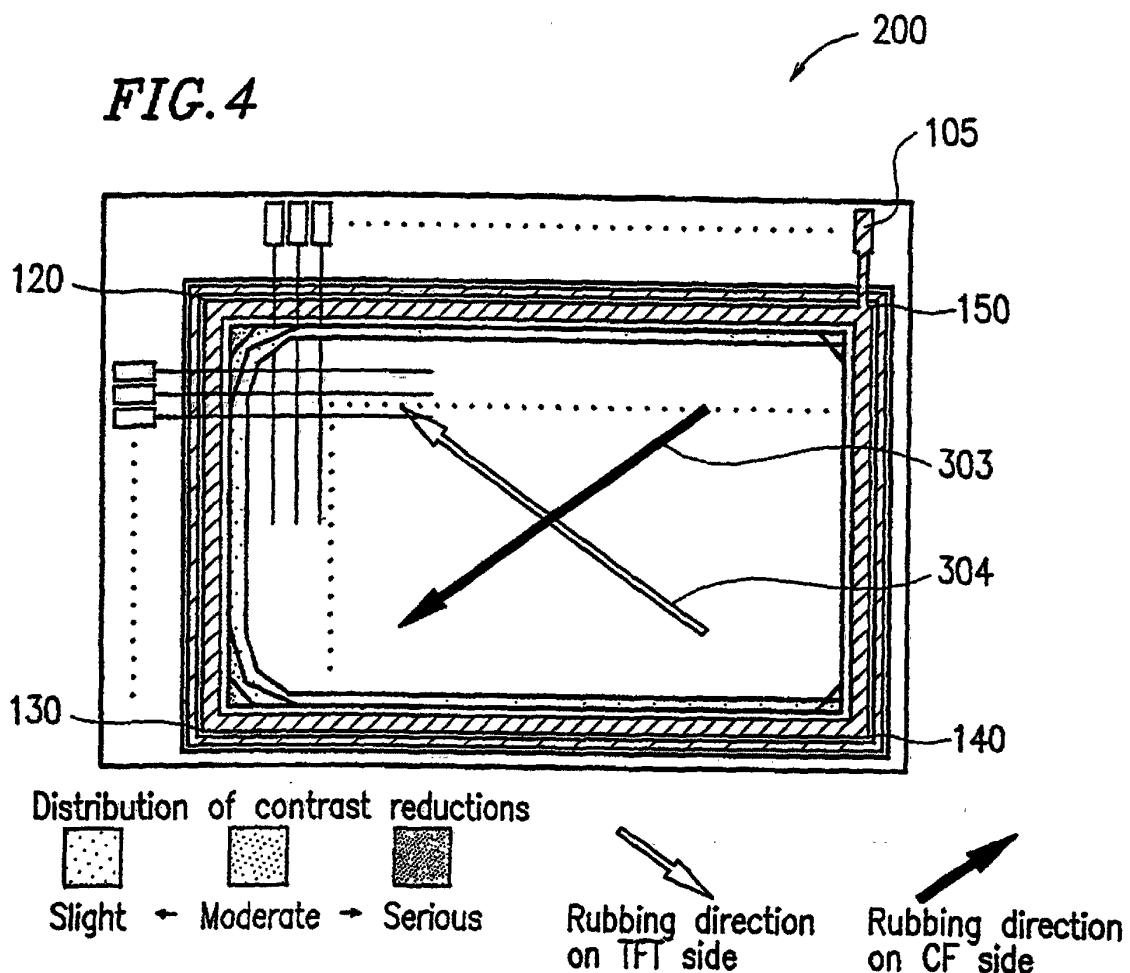


FIG. 5

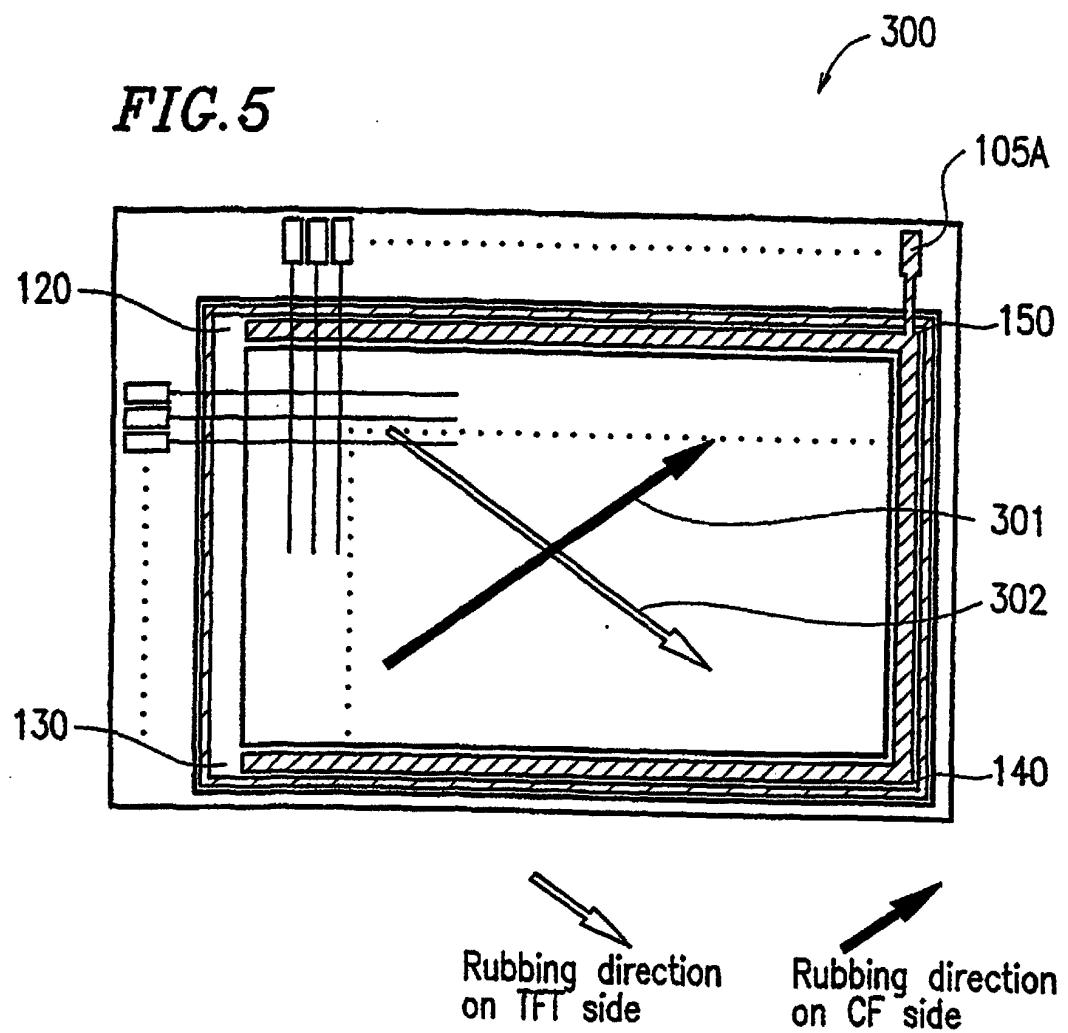


FIG. 6

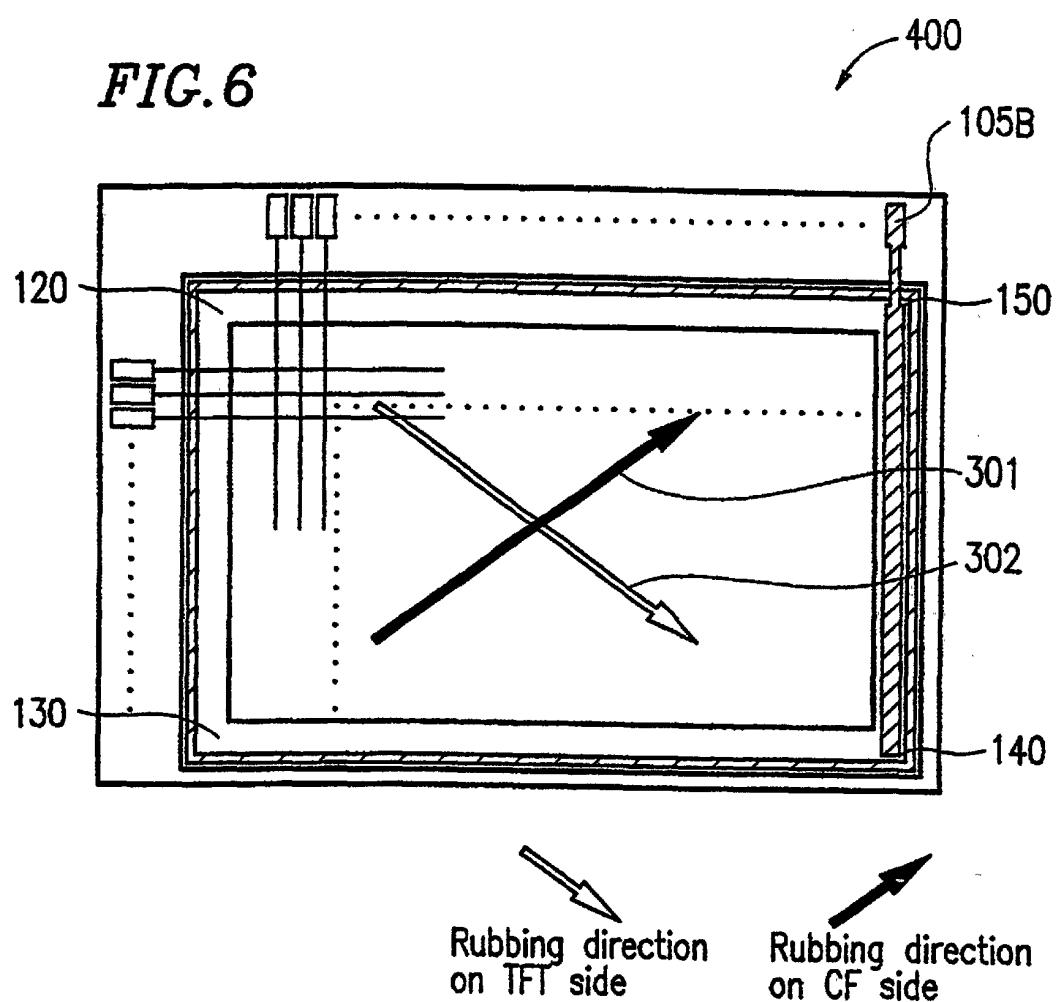


FIG. 7

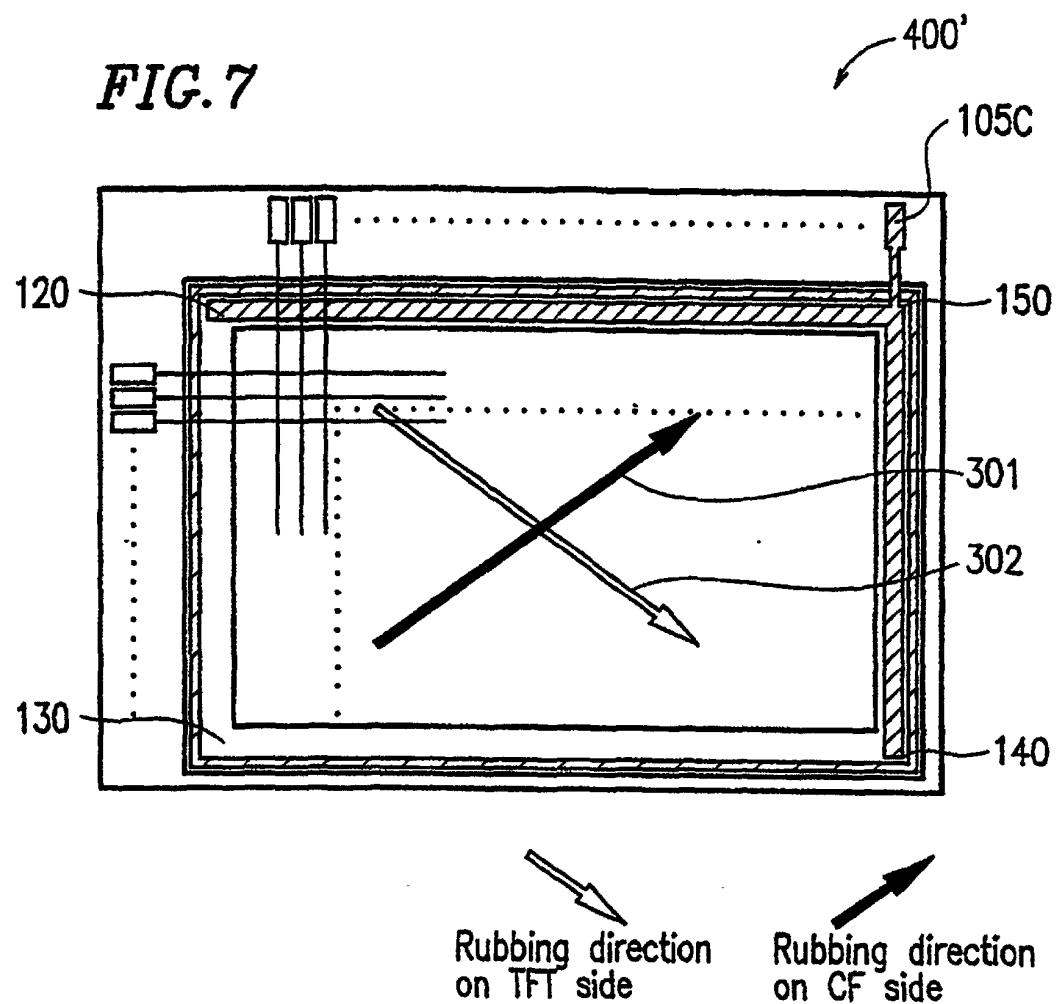


FIG.8

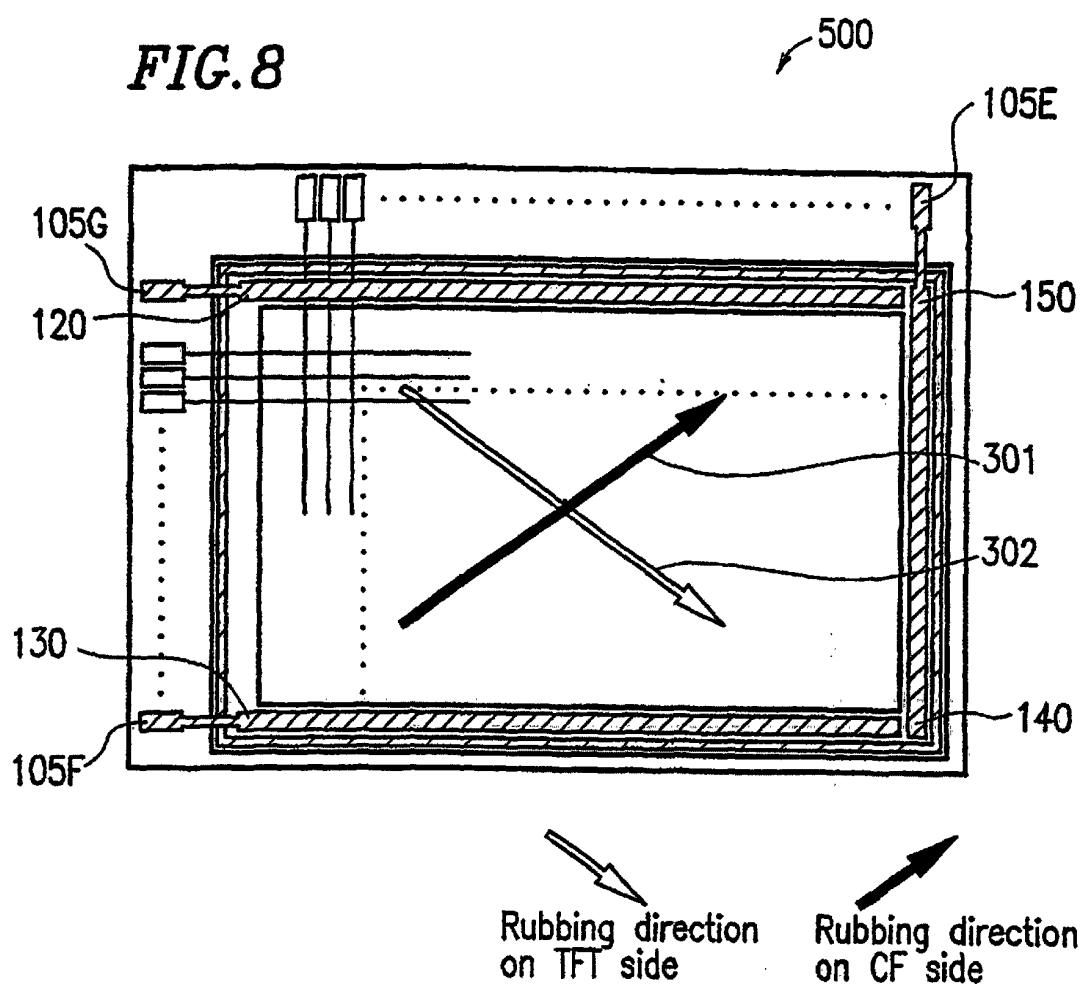
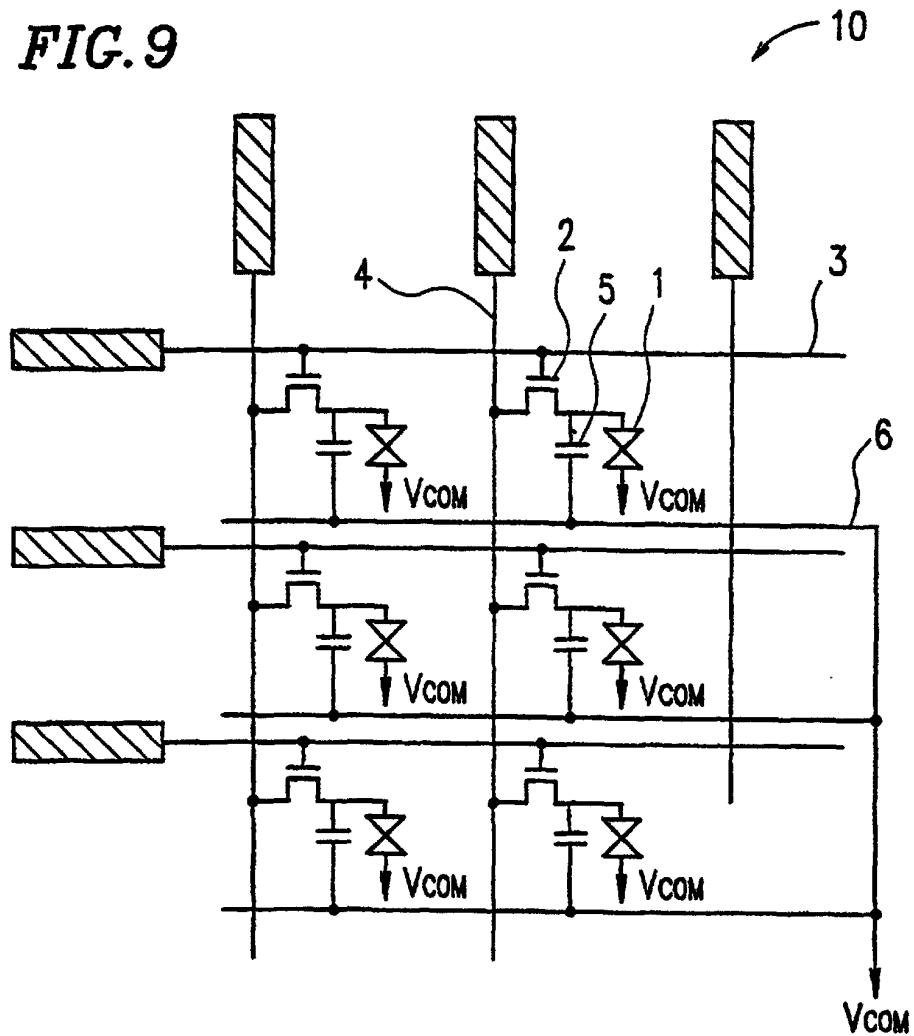


FIG. 9



专利名称(译)	液晶显示装置		
公开(公告)号	EP1055960B1	公开(公告)日	2003-04-16
申请号	EP2000110894	申请日	2000-05-23
[标]申请(专利权)人(译)	夏普株式会社		
申请(专利权)人(译)	夏普株式会社		
当前申请(专利权)人(译)	夏普株式会社		
[标]发明人	FUJIOKA KAZUYOSHI NAKAJIMA KAZUKO OKAZAKI TSUYOSHI OCHI TAKASHI		
发明人	FUJIOKA, KAZUYOSHI NAKAJIMA, KAZUKO OKAZAKI, TSUYOSHI OCHI, TAKASHI		
IPC分类号	G02F1/1333 G02F1/1337 G02F1/1343 G02F1/1345 G02F1/136 G02F1/1362 G02F1/1368		
CPC分类号	G02F1/134336 G02F1/1362 G02F2001/133337 G02F2001/133357 G02F2001/133388 G02F2001/133397		
优先权	1999145652 1999-05-25 JP		
其他公开文献	EP1055960A2 EP1055960A3		
外部链接	Espacenet		

摘要(译)

本发明的液晶显示装置包括：一对彼此相对的基板；插入在一对基板之间的液晶层；多个开关元件以矩阵图案排列在一对基板中的一个基板上；栅极信号线，用于提供用于驱动开关元件的栅极信号；源极信号线与栅极信号线交叉，用于向开关元件提供显示信号；层间绝缘膜，设置在栅极信号线和源极信号线上的一对基板上；像素电极通过层间绝缘膜设置在栅极信号线和源极信号线上。一对基板中的一个基板上的层间绝缘膜延伸到显示像素区域的周围区域。用于吸附离子杂质的电极图案设置在周围区域中的层间绝缘膜上。

FIG. 1

